

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:	) #7B
Kevin P. Martin, et al.	) Group Art Unit: 1763 /2/26/02
Serial No.: 09/855,972	Examiner: Hassanzadeh, Parviz
Filed: May 15, 2001	) Docket No. 062002-1751

METHOD AND APPARATUS FOR LOW ENERGY ELECTRON ENHANCED For: ETCHING OF SUBSTRATES IN AN AC OR DC PLASMA ERVIRONMENT

## THIRD RESPONSE WITH AMENDMENTS

Assistant Commissioner for Patents Washington, D.C. 20231

Sir:

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TO 1700 In response to the outstanding non-final Office Action mailed by the U.S. Patent and Trademark Office on September 11, 2002 (Paper No. 6), Applicants submit the following response.

It is not believed that extensions of time or fees for net addition of claims are required beyond those, which may otherwise be provided for in documents accompanying this paper. However, in the event that additional extensions of time are necessary to allow consideration of this paper, such extensions are hereby petitioned under 37 C.F.R. § 1.136(a), and any fees required therefor (including fees for net addition of claims) are hereby authorized to be charged to Deposit Account No. 20-0778.

> I hereby certify that this correspondence is being deposited with the United States Postal Service, as first class mail in an envelope addressed to: Assistant Commissioner for

Patents, Washington, D.C. 20231, on.

Signature - Gloria L. Kno.